Supplementary information for

Catalytic exchange of hydrogen isotopes intensified by two-phase stratified flow in wettability designable microchannels

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S1. Preparation of Pt/AC/PDMS coating on the walls of the microchannel reactor

The Pt/AC/PDMS coatings were prepared on the channel walls according to a "glue + powder" approach described by Li et al.^[S1] using the commercial PDMS (Sylgard 184) as the "glue" and the Pt/AC catalyst as the "powder". The diluted PDMS solution (10% w/v in *n*-hexane) was prepared by dissolving PDMS base and curing agent (a 10:1 w/w ratio) in *n*-hexane. The Pt/AC catalyst was ground and then sieved by a 200-mesh sieve prior to preparing the coatings. The procedure is specified as follows:

- (1) The channel substrate was sealed with a silicone sheet.
- (2) The diluted PDMS solution was injected into the microchannel.
- (3) A thin liquid film would be deposited on the channel walls while the excess solution was withdrawn.
- (4) The silicone sheet was opened to let hexane evaporate.
- (5) After the most of hexane was evaporated, the uncured adhesive surface was covered by the Pt/AC powder for 5 minute.
- (6) After removing the excess powder, the prepared coating was cured under 80 °C for 2 hours. The top surface of the channel substrate was cleaned so that the channel substrate could bond with the cover plate successfully.



Fig. S1. Schematic of the process for preparing Pt/AC/PDMS coating on the walls of the microchannel reactor.

S2. Calculation of the y_{HD1}^*

Rolston et al.^[S2] measured the overall deuterium (D) isotope separation factor between hydrogen and liquid water, α , at 280–370 K. The α is defined as eqn (S1). The correlation between α and temperature (*T*, K) is presented as eqn (S2). Based on the mass balance of D, the D abundance in the liquid water at outlet of the microchannel reactor (x_{D1}) is calculated by eqn (S3). The equilibrium D abundance in hydrogen at the outlet (y_{D1}^*) can be calculated by eqn (S4) transformed from eqn (S1). The equilibrium molar fraction of HD in hydrogen at the outlet (y_{HD1}^*) is twice the y_{D1}^* calculated as eqn (S5).

$$\alpha = \frac{x_{\rm D}^*(1 - y_{\rm D}^*)}{y_{\rm D}^*(1 - x_{\rm D}^*)}$$
(S1)

$$\ln \alpha = -0.2143 + \frac{368.9}{T} + \frac{27870}{T^2}$$
(S2)^[S2]

$$x_{\rm D1} = \frac{2x_{\rm D0}F_{\rm H_2O} - (y_{\rm HD1} - y_{\rm HD0})F_{\rm H_2}}{2F_{\rm H_2O}}$$
(S3)

$$y_{\rm D1}^* = \frac{1}{1 - \alpha + \alpha / x_{\rm D1}}$$
(S4)

$$y_{\rm HD1}^* = 2y_{\rm D1}^*$$
 (S5)

where x_D^* and y_D^* are the equilibrium D abundances in liquid water and hydrogen, respectively; x_{D0} is the D abundance in liquid water at inlet of the microchannel reactor; $F_{H_{2}O}$ and F_{H_2} are the feeding molar flow rates of water and hydrogen, respectively; y_{HD0} and y_{HD1} are the molar fractions of HD in hydrogen at inlet and outlet of the microchannel reactor, respectively.



Fig. S2. Effects of liquid flow rate (q_L) on flow patterns at a given gas flow rate ($q_G = 15.0 \text{ mL min}^{-1}$) in the 1S3H, 2S2H-1, 3S1H(1) and 3S1H(2) microchannels.



Fig. S3. Effects of temperature (*T*) on molar fraction (y_{HD1}) and equilibrium molar fraction (y_{HD1}^*) of HD in hydrogen at outlet of the microchannel reactor at $x_{D0} = 0.03$, $q_{H2O} = 2.0$ mL h⁻¹ and $q_{H2} = 12.0$ mL min⁻¹.



Fig. S4. Effects of hydrogen $(q_{\text{H}2})$ and water $(q_{\text{H}2\text{O}})$ flow rates on average D abundance in the water flow $(x_{\text{D}} = (x_{\text{D}0} + x_{\text{D}1})/2)$ of the microchannel reactor at $x_{\text{D}0} = 0.03$ and T = 60 °C.



Fig. S5. Effects of hydrogen (q_{H_2}) and water $(q_{H_{2O}})$ flow rates on molar fraction (y_{HD1}) and equilibrium molar fraction (y_{HD1}^*) of HD in hydrogen at outlet of the microchannel reactor at $x_{D0} = 0.03$ and T = 60 °C.



Fig. S6. Effects of hydrogen (q_{H_2}) and water $(q_{H_{2O}})$ flow rates on deuterium removal capacity (DC) in the microchannel reactor at $x_{D0} = 0.03$ and T = 60 °C.

References

[S1] Z. Li, M. Cao, P. Li, Y. Zhao, H. Bai, Y. Wu and L. Jiang, *Matter*, 2019, 1, 661–673.
[S2] J. H. Rolston, J. Den Hartog and J. P. Butler, *J. Phys. Chem.*, 1976, 80, 1064–1067.